Quadrant Analysis in Correlation between Mechanical and Electrical Properties of Low-Temperature Conductive Film Bonded Crystalline Silicon Solar Cells

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ABSTRACT: In this study, we analyzed the correlation between mechanical and electrical properties of low-temperature conductive film (LT-CF) bonded silicon solar cells by a quadrant analysis (horizontal axis (peeling strength), vertical axis (power loss)). We found that a series of points with various bonding parameters such as bonding temperature, pressure and time were distributed in the different three regimes; weak regime (Q2: weak bonding strength and high power loss), moderate regime (Q4 : strong bonding strength and low power loss) and hard regime (Q3 : weak bonding strength and low power loss). Using this analogous technique, it was possible to fabricate the LT-CF bonded silicon solar cells with the various conditions displayed in Q3 of the quadrant plots, possessing the peeling strength of ~ 1N/mm and power loss of $2\sim3\%$.

Key words: Low-temperature conductive film, PV module, bonding, peeling strength, power loss

1. Introduction

Low-temperature conductive film (LT-CF) bonding has been widely investigated in the semiconductor packaging and manufacturing industry as an alternative method to soldering¹⁻³⁾. Recently, LT-CFs for fabricating solar cell strings were introduced and commercialized.

Epoxy-resin-based LT-CF is especially sensitive to bonding parameters such as bonding temperature, pressure and time. In general, strong mechanical contacts between metal ribbons and cells guarantee good electrical properties. However, when LT-CF faces an over-curing and excess compression, adhesion strength and electric properties are suffered from deterioration.

In this study, we analyzed the correlation between mechanical (peeling strength) and electrical properties (power loss) of LT-CF bonded silicon solar cells by a quadrant analysis (horizontal axis (peeling strength), vertical axis (power loss)). Using the analogous technique, we found that a series of points with various bonding

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parameters such as bonding temperature, pressure and time were distributed in the different three regimes; weak regime (Q2: weak bonding strength and high power loss), moderate regime (Q4 : strong bonding strength and low power loss) and hard regime (Q3 : weak bonding strength and low power loss). Based on these analysis results, the bonding conditions between solder- & flux-free ribbons and cells were carefully optimized. We will discuss the correlation between mechanical (peeling strength) and electrical properties (power loss) of LT-CF bonded silicon solar cells in details.

2. Experiments

The LT-CF used in this study was CF-205 (25- μ m-thick and 1.2-mm-wide, Hitachi Chemical). It was inserted between a Pb-free ribbon and a monocrystalline silicon solar cell (6 inch, 3-bus bar, 4.54 Wp). In order to optimize the bonding conditions, various parameters were examined. The bonding temperature was varied from 110 to 210°C, and the bonding time was varied from 1 to 7 s. Further, the bonding pressure was varied from 1 to 4 MPa.

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The procedure for LT-CF bonding consists of the following steps: LT-CF placement on cells, pre-bonding, PFR placement, and final bonding. The whole procedure was automatically carried out using a pilot apparatus (ARCF-700), which is capable of interconnecting 700 cells/h. The surface of LT-CFs was observed by stereo optical microscope (Olympus SZX7). To measure the adhesion strength, the 90° peel test was carried out. The bonded three ribbons on the cells were peeled-off, and the peel strength was measured using a peel tester (IMADA, DS2-20N) at a peeling speed of 0.7 mm/s. Power loss in the solar cell was analyzed before and after the bonding process, and power output was simulated using a flash system (McScience, Lab200) with the AAA class in spectrum.

3. Results and discussion

3.1 Morphology analysis

In order to clarify the morphology changes and failure modes of LT-CF after the bonding process according to the bonding parameters, top-view images of LT-CFs after removal of ribbons were observed by the stereo optical microscope, as shown in Fig. 1. Fig. 1(a), (b) and (c) show the results for the samples bonded at 130, 180 and 210°C, respectively. For all samples, pressure and time were fixed at 2 MPa and 2 s, respectively.

The original width of the LT-CF and ribbon were 1.2 and 1.5 mm. However, the widths after bonding as obtained from their top-view images were 1.55, 1.61 and 1.86 mm for the samples bonded at 130, 180 and 210°C, respectively. This implies that LT-CF beneath the ribbon flowed out after the bonding process and flowed out more as the temperature increased. While, roughly formed surface textures for the samples bonded at 130°C were observed, which is the typical inadequate cohesive failure mode due to an insufficient degree of cure⁴. However, the surface

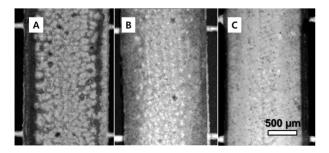


Fig. 1. Top-view images of LT-CFs after removal of ribbons observed by the stereo optical microscope ; bonded at (A)130, (B)180 and (C)210°C

morphology was gradually smoother as the bonding temperature increased, corresponding to the interface failure mode, which is observed when LT-CF is cured over 90%⁴⁾. Even though the dependence of failure modes on the various bonding temperatures were only displayed here, it is expectable that curing degree determines the failure mode and both mechanical and electrical bonding strength.

3.2 Quadrant analysis

A conventional characterization method to determine the curing degree of LT-CFs is comparing the two peak areas derived from an epoxy functional group at 915 cm⁻¹ and an aromatic ring band at 1507 cm⁻¹ using FT-IR⁵). However its reproducibility is low and the less direct method than the peeling test. Furthermore, we found that the conditions showing the superior electrical property did not guarantee the good mechanical strength. Therefore, we adopted quadrant analysis on the correlation between mechanical (peeling strength, horizontal axis) and electrical properties (power loss, vertical axis) of LT-CF bonded silicon solar cells to optimize the bonding conditions.

3.2.1 Bonding temperature

Fig. 2 shows the correlation between peeling strength and power loss of the samples bonded with various bonding temperatures from 110 to 210°C; the other parameters were maintained constant, for 5 s under 2 MPa. Using the quadrant analysis, we found that a series of points were distributed in the different three regimes; weak regime (Q2: weak bonding strength

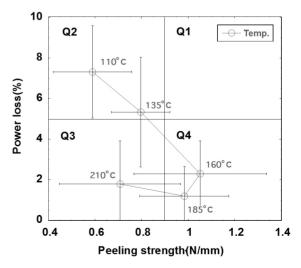


Fig. 2. Correlation between peeling strength and power loss of the samples bonded with various bonding temperatures from 110 to 210°C; the other parameters were maintained constant, for 5 s under 2 MPa

and high power loss), moderate regime (Q4 : strong bonding strength and low power loss) and hard regime (Q3 : weak bonding strength and low power loss). However, there existed no data in Q1, i.e. hard bonding and high power loss.

As the temperature increased, both peeling strength and power loss were improved (Q2 : $110 \sim 135^{\circ}C \rightarrow Q4$: $160 \sim 185^{\circ}C$) and those were deteriorated with further increased bonding temperature (Q4 : $160 \sim 185^{\circ}C \rightarrow Q3$: $>210^{\circ}C$). It should be pointed out that the decrease in the power loss of the sample in Q4 was much less than that of peeling strength,

Where the peeling strength was as low as the data in Q2. This result is attributed that the density of cross-linkage increases, as the temperature increased resulting in enhanced rheological properties of LT-CF at the interface. However, a too high temperature causes over-curing of CF and decreases adhesion strength⁶⁾. On the other hand, excess compression conditions promoted over-curing but formed a sufficient pathway made of conductive particles to result in a power loss of only $2\sim3\%$. It is expected that samples with weak peeling strength are clearly vulnerable to humidity, thermal and physical shocks, etc., which deteriorates their long-term reliability.

3.2.2 Bonding time

Fig. 3 shows the correlation between peeling strength and power loss of the samples bonded with various bonding times from 2 to 9 s; the other parameters were maintained constant, at 185°C under 2 MPa. The behavior of the series of points due to bonding time shown in Fig. 2 was similar to that of bonding temperatures. As bonding time increased, peeling strength was drastically dropped and electric contact was slightly improved at the inflection point, 4s. This indicates that in regime Q1, bonding time was too short to achieve a sufficient curing degree, but in regime Q3, long bonding time promoted over-curing. However, uniformity was improved gradually as the bonding time increased.

3.2.3 Bonding pressure

Fig. 4 shows the correlation between peeling strength and power loss of the samples bonded with various bonding pressures from 1 to 4 Mpa; the other parameters were maintained constant, at 185°C for 5 s. The behavior of the series of points due to bonding pressure was slightly different from those of both temperature and time. All data were existed in Q3 and Q4. It means that LT-CF is sensitive to temperature and time rather

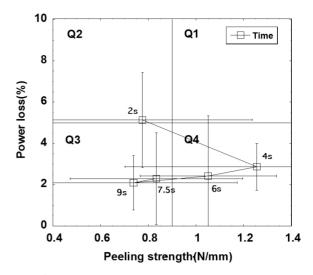
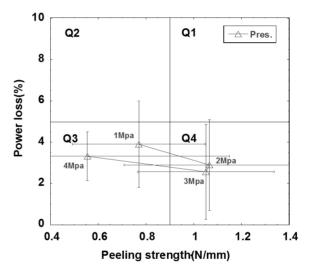
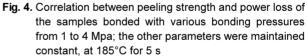


Fig. 3. Correlation between peeling strength and power loss of the samples bonded with various bonding times from 2 to 9 s; the other parameters were maintained constant, at 185°C under 2 MPa





than pressure. Too low or high bonding pressures worsened both peeling strength and power loss. These results presumably account for inadequate adhesion and over-curing, respectively. An excessively high bonding pressure may induce compressive stress in LT-CF and internal stress in bonding areas⁷.

Conclusions

In conclusion, it was possible to fabricate the LT-CF bonded silicon solar cells with the various conditions displayed in Q3 of the quadrant plots possesing the peeling strength of ~ 1 N/mm

and power loss of 2~3%. Even though the samples displayed in Q3 showed comparatively good electrical contact properties, the mechanical strength was not enough to expect a long life time. This result is attributed to a sufficient pathway made of conductive particles despite of over-curing. However, it is expected that samples with weak peeling strength are clearly vulnerable to humidity, thermal and physical shocks, etc., which deteriorates their long-term reliability. Additionally, data distributions in the quadrant plots due to various bonding conditions reveled that LT-CF is sensitive to the order of temperature, time and pressure.

Acknowledgments

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